

Virtual Research Presentation Conference

Development of Deep-Ultraviolet Solid-State Lasers for Raman Spectroscopy

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Jet Propulsion Laboratory California Institute of Technology

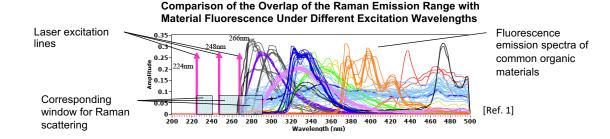
Assigned Presentation # R20101

Tutorial Introduction



Abstract

Spectroscopic analysis techniques such as Raman spectroscopy and luminescence measurements benefit immensely from the utilization of deep-ultraviolet coherent light sources. Deep-ultraviolet excitation provides multiple benefits which collectively contribute to an enhanced detection capability, for biosignatures and other species of interest. The current work aims to develop a solid-state platform for the generation of coherent deep-ultraviolet light. The technology concept relies on borate-based nonlinear optical crystal layers, which feature a broad transparency window and are capable of frequency upconversion into the deep-ultraviolet range. The implemented platform utilizes integrated photonic components to fulfill phase matching and additionally enhance the conversion efficiency of the device.



Problem Description

a) Context

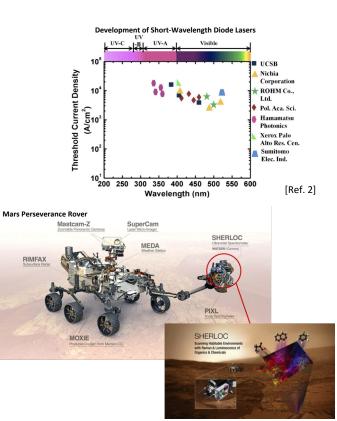
- a) Compact deep-ultraviolet (deep-UV) coherent light sources are required for spectroscopic analysis on planetary exploration missions
- b) State-of-the-art technology for coherent deep-UV sources faces technical hurdles, resulting in devices with limited performance and reliability

b) Comparison with State-of-the-Art

Criterion	State-of-the-Art NeCu Gas Laser	Proposed Solid-State Laser
Mass	470 g	~100 g
Power Output	~40 μs of <20 μW @80 Hz,	>1 mW, continuous-wave
	pulsed	
Volume/Size	~500 cm ³ /	<250 cm ³ /
	~5 cm diameter, 25 cm length	~1 cm ² chip area
Emission Wavelength	248.6 ± 0.05 nm (fixed)	Any wavelength down to 225 nm
Beam Quality (M ²)	>30	≈1.1 (near diffraction limit)
Robustness	Gas tube	Solid-state components
Spot Size	~100 microns	<3 microns

c) Relevance to NASA and JPL

- a) Raman spectroscopy and luminescence spectroscopy instruments are essential tools for life detection and assessment of habitability
- b) The developed technology will contribute to planetary instruments carried on upcoming exploratory missions, which will require reliable and robust devices

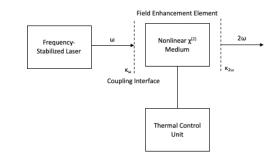


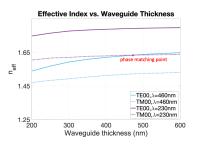
Methodology

a) Formulation

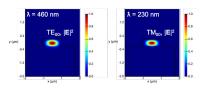
- a) Raman spectroscopy and other spectroscopic techniques benefit greatly from deep-UV sources
- b) Deep-UV generation can be generated in nonlinear media with shortwavelength transparency combined with suitable dispersion properties
- c) Cladded optical-grade β-barium borate (β-BBO) layers enable the fabrication of integrated photonic elements
- d) Phase-matching in nonlinear waveguides is required for efficient nonlinear frequency conversion
- b) Innovation / Advancement
 - a) A novel thin-layer β-BBO-on-insulator platform supports nonlinear optical processes spanning the near-infrared to deep-ultraviolet range
 - b) Phase matching can be precisely engineered using integrated photonic elements
 - c) Compact, high-power semiconductor light sources can be incorporated as optical pumps

Deep-UV Generation Scheme





β-BBO Waveguide Modal Field Profiles



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Results

a) Goals and accomplishments

- a) Development of designs for nonlinear frequency conversion
 - \rightarrow Phase-matched β-BBO nonlinear waveguides designed
- b) Demonstration of patterning in free-standing β-BBO crystal

 \rightarrow High-aspect ratio (> 5:1) patterning of β-BBO crystal demonstrated using focused-ion-beam milling

 \rightarrow Anhydrous electron-beam lithographic patterning of β -BBO implemented and is in the optimization phase

c) Thin-layer development for β -BBO

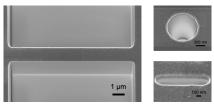
 \rightarrow Initial implementation of thin β-BBO layers (5 µm-thickness) using optical-grade polymer cladding, currently being transitioned to silica cladding

d) Implementation of a measurement testbed

→ Measurement setup has been implemented for the characterization of visible-todeep-UV integrated photonic chips

Focused-Ion-Beam Patterning

Electron-Beam Lithography

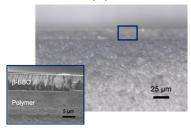


1um

Micro/nanoscale features directly milled in free-standing β -BBO crystals.

Patterned chromium hard mask on β -BBO free-standing crystal through anhydrous processing.

Thin-Layer β-BBO



Cross-sectional brightfield microscopy image of thin layer β -BBO, and the corresponding scanning electron microscopy close-up in the inset. The cross-sectional cut was prepared by dicing.

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Results

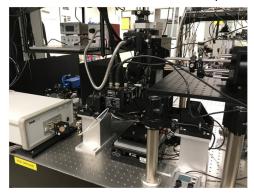
a) Significance

- a) Existing nonlinear optical layers do not operate in the short-visible to deep-UV wavelength range
- b) A mature micro-/nano-scale fabrication process for β -BBO has not been developed yet
- c) This technology development is unique and complements the UV detection competency at the Microdevices Laboratory

b) Next steps

- a) Optimization of the fabrication process
- b) Fabricating and testing the designed photonic chips to target propagation losses below 5 dBcm^{-1} in β -BBO waveguides at the pump wavelength

Measurement Testbed at the Microdevices Laboratory



Publications and References

Publications:

New Technology Report # 51684, "Method for the Preparation of Thin-Layer Beta-Barium Borate"

References:

[1] W. F. Hug et al., Chemical and Biological Sensors for Industrial and Environmental Monitoring II 6378, 63780S (2006).

[2] S. Zhao and Z. Mi, IEEE J. Quantum Electron. 54, 1-9 (2018).

Acknowledgements

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